Adam Pranda

List of Publications by Year in descending order

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1937685 1720034 7 59 4 7 citations h-index g-index papers 7 7 7 66 docs citations citing authors times ranked all docs

#	Article	IF	CITATIONS
1	Polymer etching by atmosphericâ€pressure plasma jet and surface microâ€discharge sources: Activation energy analysis and etching directionality. Plasma Processes and Polymers, 2018, 15, 1700217.	3.0	24
2	Validation of etching model of polypropylene layers exposed to argon plasmas. Plasma Processes and Polymers, 2019, 16, 1900019.	3.0	11
3	Role of the dense amorphous carbon layer in photoresist etching. Journal of Vacuum Science and Technology A: Vacuum, Surfaces and Films, 2018, 36, 021304.	2.1	10
4	Evolution of photoresist layer structure and surface morphology under fluorocarbonâ€based plasma exposure. Plasma Processes and Polymers, 2019, 16, 1900026.	3.0	6
5	Significance of plasma-photoresist interactions for atomic layer etching processes with extreme ultraviolet photoresist. Journal of Vacuum Science and Technology A: Vacuum, Surfaces and Films, 2020, 38, .	2.1	4
6	Substrate temperature effect on migration behavior of fluorocarbon film precursors in high-aspect ratio structures. Journal of Vacuum Science and Technology B:Nanotechnology and Microelectronics, 2019, 37, 031802.	1.2	3
7	Effect of nonvertical ion bombardment due to edge effects on polymer surface morphology evolution and etching uniformity. Journal of Vacuum Science and Technology A: Vacuum, Surfaces and Films, 2021, 39, .	2.1	1